

Current and Capacitance Summary Tables

Table 1. Single-pad device leakage current and current density across devices at a 400 V bias

Device type	I_{leak} [μA]	$J_{leak, pad}$ [$\mu\text{A}/\text{cm}^2$]
Unirradiated pad, with opening	31.4	7.85
Unirradiated pad, no opening	32.9	8.23
Unirradiated total, with opening	38.8	9.70
Unirradiated total, no opening	44.2	11.1
10^{13} n/cm ² pad, with opening	36.5	9.13
10^{13} n/cm ² pad, no opening	35.7	8.93
10^{14} n/cm ² pad, with opening	70.7	17.7
10^{14} n/cm ² pad, no opening	77.3	19.3

Table 2. Single-pad device capacitance [pF] across devices, unirradiated

Device type	$C_{1kHz, +/- 10V}$	$C_{1MHz, +/- 10V}$
Pad, with opening	2.17 / 2.52	2.08 / 2.08
Pad, no opening	2.21 / 2.55	2.10 / 2.10
Pad w/ GR, with opening	1.83 / 1.84	1.77 / 1.77
Pad w/ GR, no opening	1.86 / 1.79	1.76 / 1.77

Alpha Parameter Results - Old

Damage Coefficient alpha -- Free-Intercept Linear Fit (Floating)
 $I/V = \alpha * \Phi + b$ (star = unirradiated at $\Phi = 0$)

Voltage = 400 V

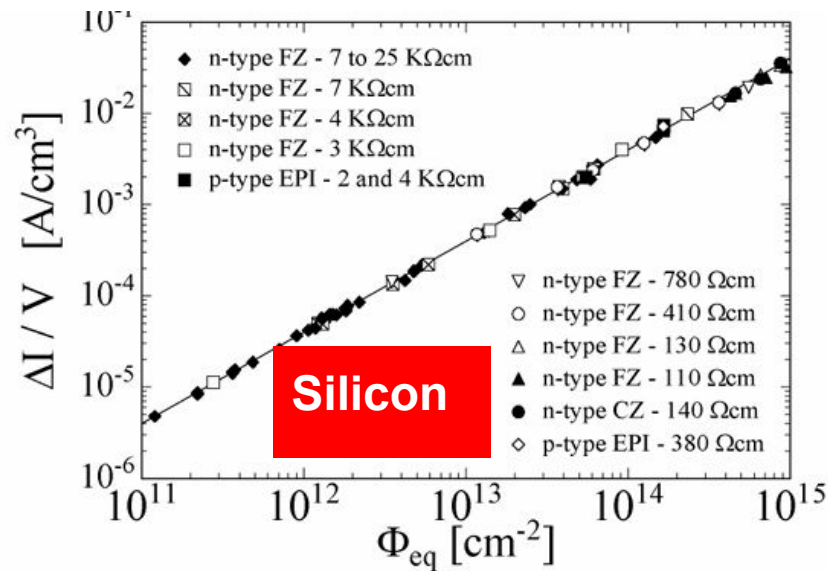
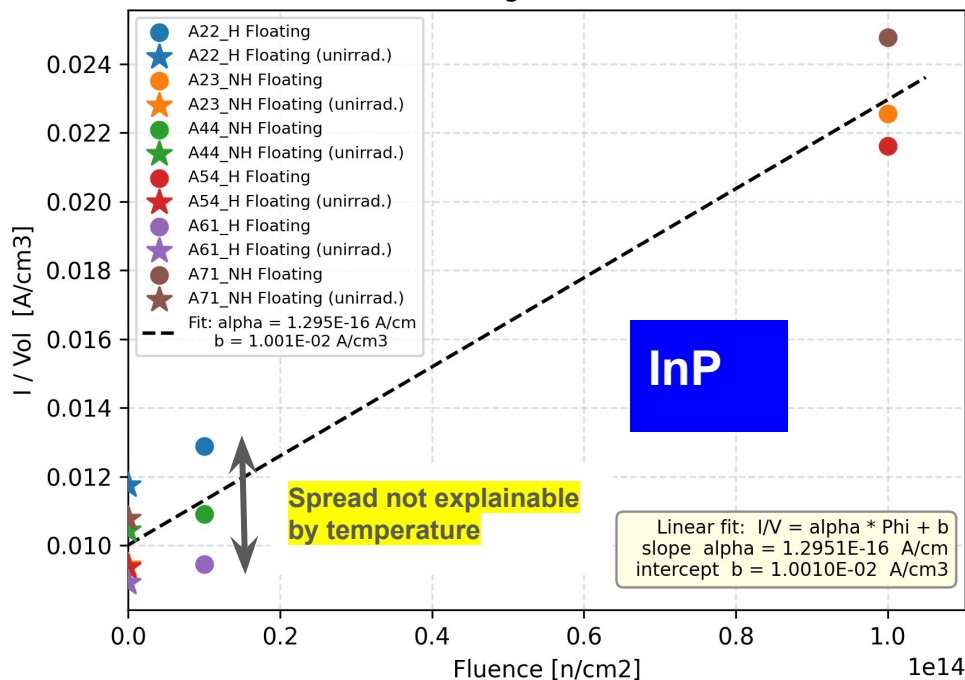


Figure 5.1: Fluence dependence of leakage current for silicon detectors produced by various process technologies from different silicon materials. The current was measured after a heat treatment for 80 min at 60°C $\{\alpha(80 \text{ min}, 60^\circ\text{C}) = (3.99 \pm 0.03) \times 10^{-17} \text{ A/cm}\}$; for details see Fig. 5.6}.

Alpha Parameter Results - Updated

Damage Coefficient alpha -- Free-Intercept Linear Fit (Floating)
 $\Delta I / \text{Vol} = \text{alpha} * \Phi + b$ (star = unirradiated at $\Phi = 0, \Delta I = 0$)

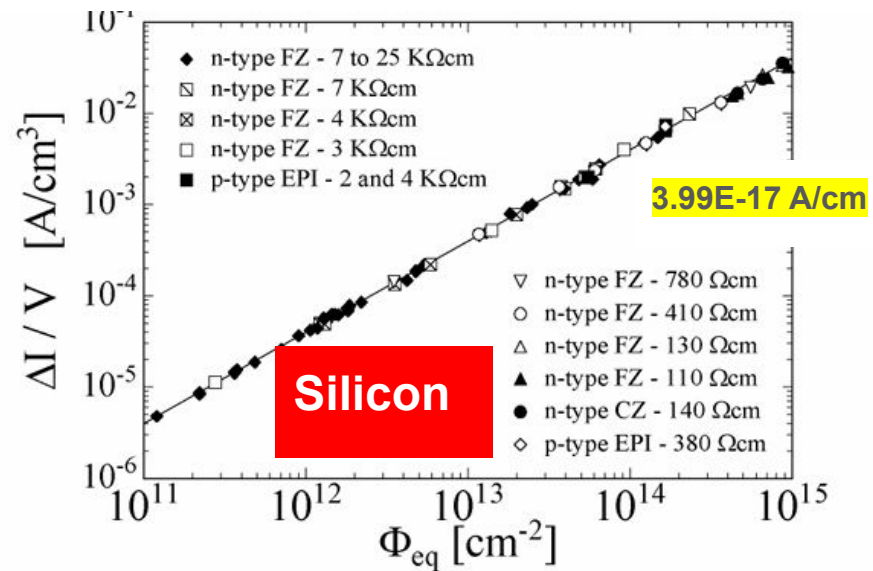
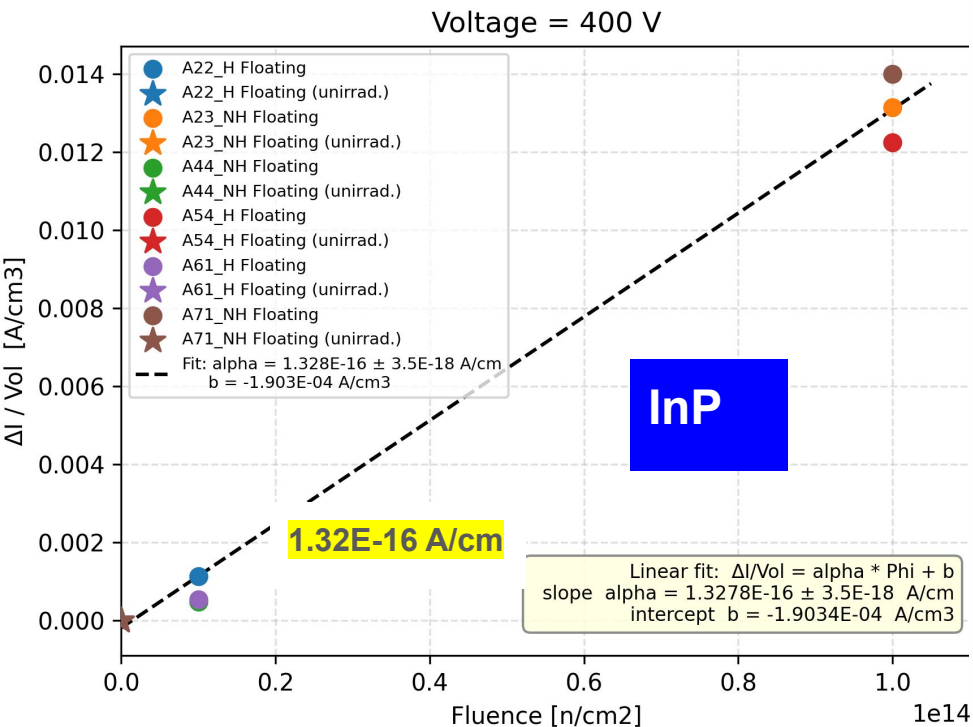


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Arrhenius Equation

5. Arrhenius (temperature plot, `temperature_arrhenius_fit_parameters.csv`)

$$|I(T)| = A \cdot \exp\left(-\frac{E_a}{k_B T_K}\right) \quad \text{with } T_K = T_C + 273.15$$

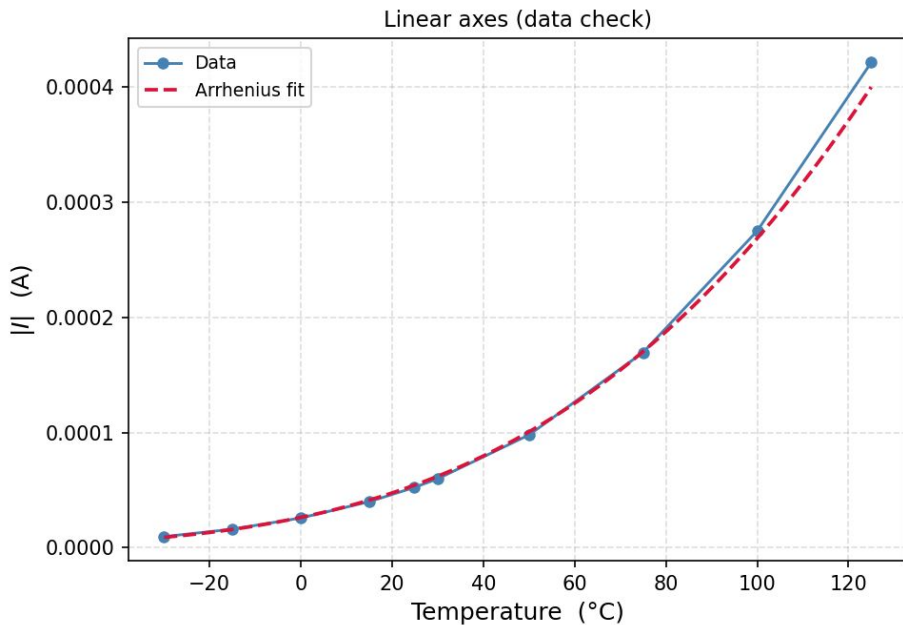
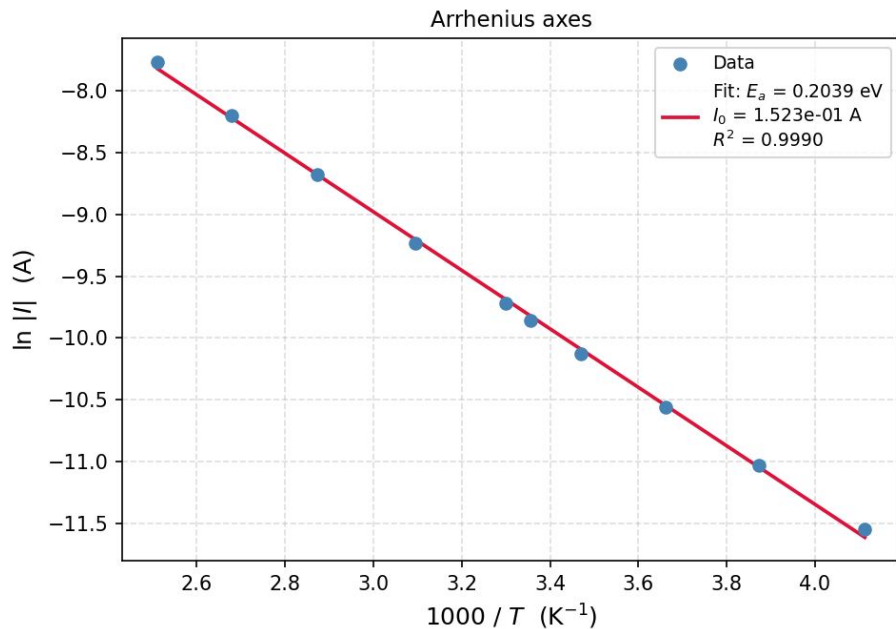
Fit performed by linear regression on $\ln |I|$ vs $1/T_K$:

$$\ln |I| = \ln A - \frac{E_a}{k_B} \cdot \frac{1}{T_K}$$

so slope = $-E_a/k_B$, intercept = $\ln A$. E_a reported in eV using $k_B = 8.617333262 \times 10^{-5}$ eV/K.

Simulation - Arrhenius Reconstruction - 450 V

450V_Temp (bias = +450.0 V)

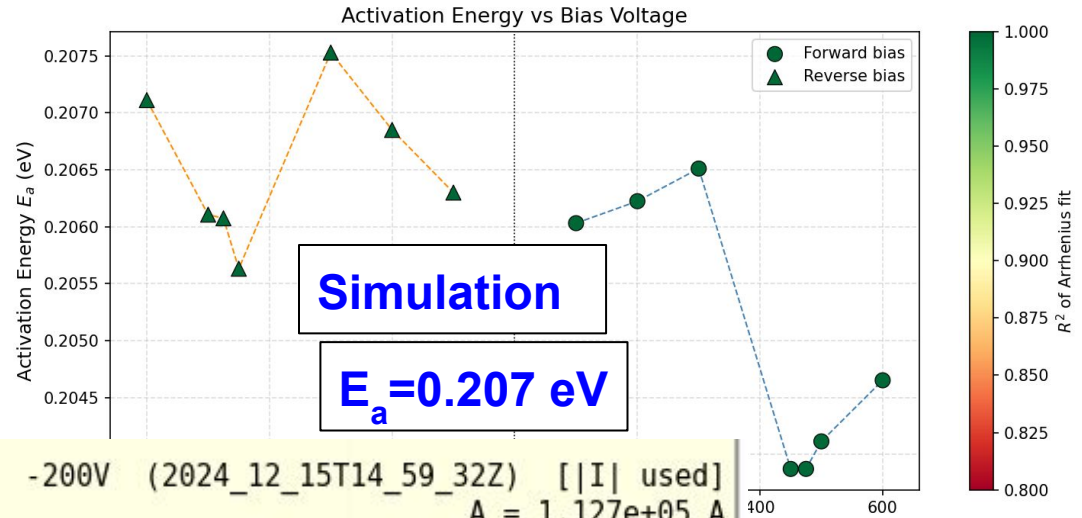


Arrhenius plots from going over Richville's simulations: [Link](#)

Simulation - Arrhenius Reconstruction

- Simulation Reconstructed E_a
 - Self-consistent within 2%
 - less than half of conduction -to-trap-center gap ?
 - $E_a \neq$ gap to middle of trap state?

- Pure InP Bandgap: ~ 1.3 eV



Simulation

$E_a = 0.207$ eV

```

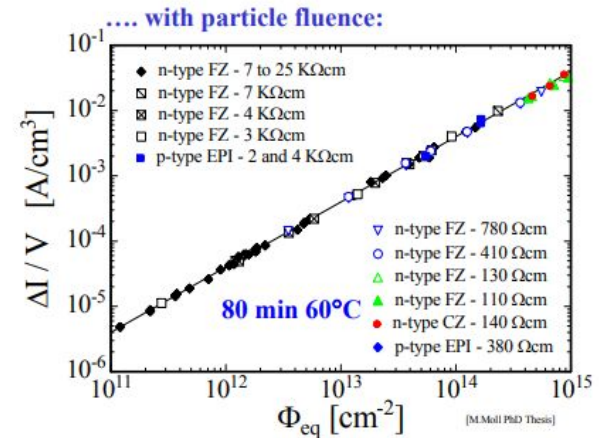
-200V (2024_12_15T14_59_32Z) [|I| used]
                                A = 1.127e+05 A
σ_raw = 3.62e+03      σ_infl = 8.38e+03 (x5.35)
                                Ea = 0.563 eV
σ_raw = 0.000732     σ_infl = 0.00169 (x5.35)
(563.05 meV; σ_raw = 0.73, σ_infl = 1.69 x5.35)
R^2 = 0.9997      n = 201      τ_int = 2.18
    
```

Data Fit

Backup

Overview

- InP devices irradiated in Ljubljana:
 - 1E13-1E16 / 1 MeV n eq
- Radiation hardness of a material (to hadrons) can be summarized by the damage parameter **alpha**
 - aka **current related damage rate**
 - Invariant to doping, thickness, impurities
 - Proportional to fluence
- Accurate measurement requires two conditions
 - Constant ambient temperature
 - Known effective volume



$\alpha(t) \ll 10^{-17}$ A/cm

- **Damage parameter α (slope in figure)**

$$\alpha = \frac{\Delta I}{V \cdot \Phi_{eq}}$$

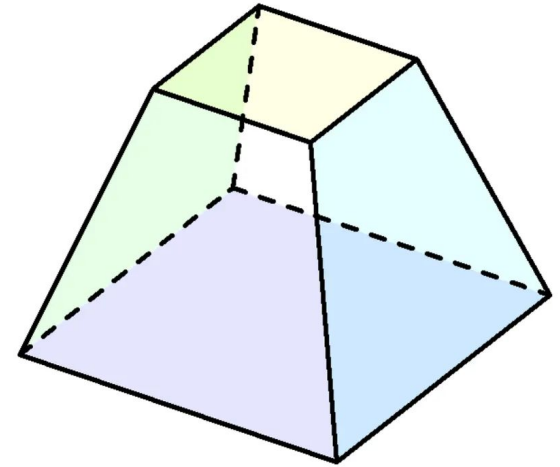
Leakage current
per unit volume
and particle fluence

- **α is constant over several orders of fluence and independent of impurity concentration in Si**
 ⇒ can be used for fluence measurement

Caveat: Two Conditions Not Fulfilled

- Effective volume not constrained

- **Floating guard ring**
 - Standard IV station does not have multiple channels to measure guard ring and central pad separately
- Effective volume spreads beyond under central pad
- Effective volume estimated as frustrum



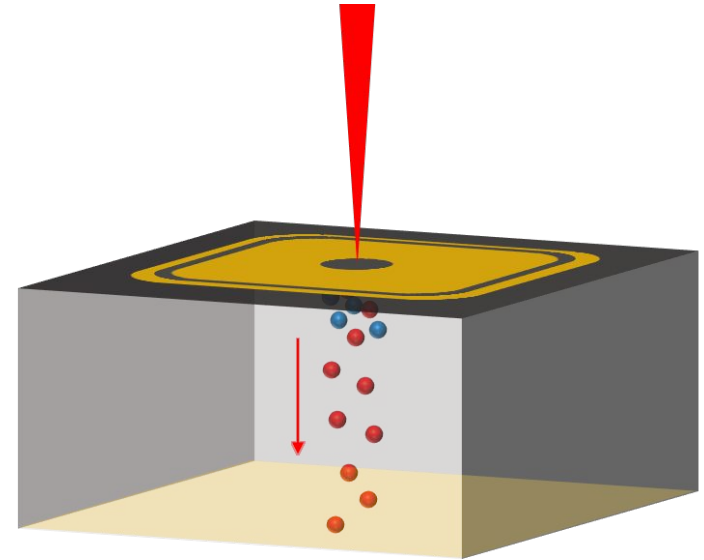
- Temperature not held constant

- Temperature not held constant/measured + measurements taken on different days
- Leakage current temperature dependence will spread values

- Presented will be preliminary estimation of alpha

Caveat: No 'Reverse Bias' State

- Our devices are essentially asymmetric capacitors
 - Uniform doping
 - Single pad
 - No saturation current
- Alpha parameter assumes saturation current
 - Leakage current is dependent on choice of voltage for our devices
- Decision: choose characteristic voltage
 - Match to voltage shown in InP Paper
 - + 400 V on backside of device, central pad held at 0 V



Schematic by Jennifer Ott

Results

Damage Coefficient alpha -- Free-Intercept Linear Fit (Floating)
 $I/V = \alpha * \Phi + b$ (star = unirradiated at $\Phi = 0$)

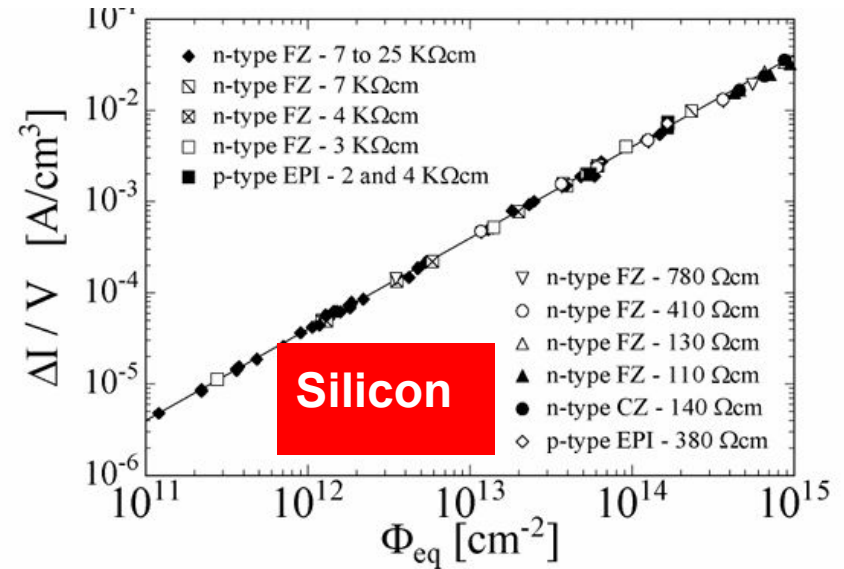
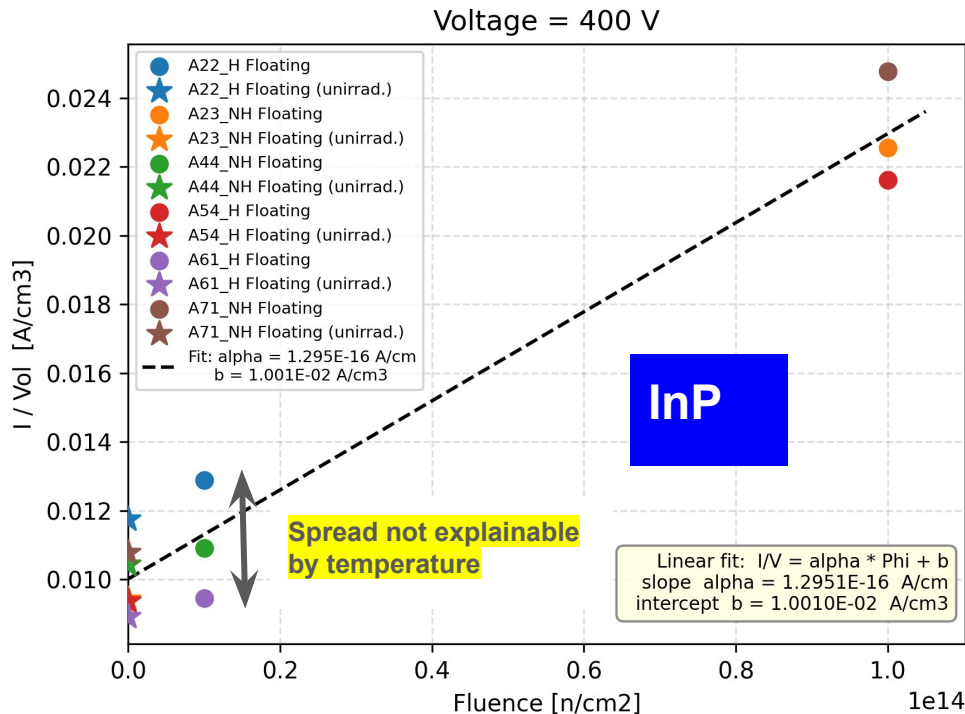
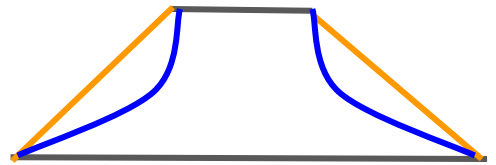


Figure 5.1: Fluence dependence of leakage current for silicon detectors produced by various process technologies from different silicon materials. The current was measured after a heat treatment for 80 min at 60°C $\{\alpha(80 \text{ min}, 60^\circ\text{C}) = (3.99 \pm 0.03) \times 10^{-17} \text{ A/cm}^3\}$; for details see Fig. 5.6}.

Comparison with Silicon

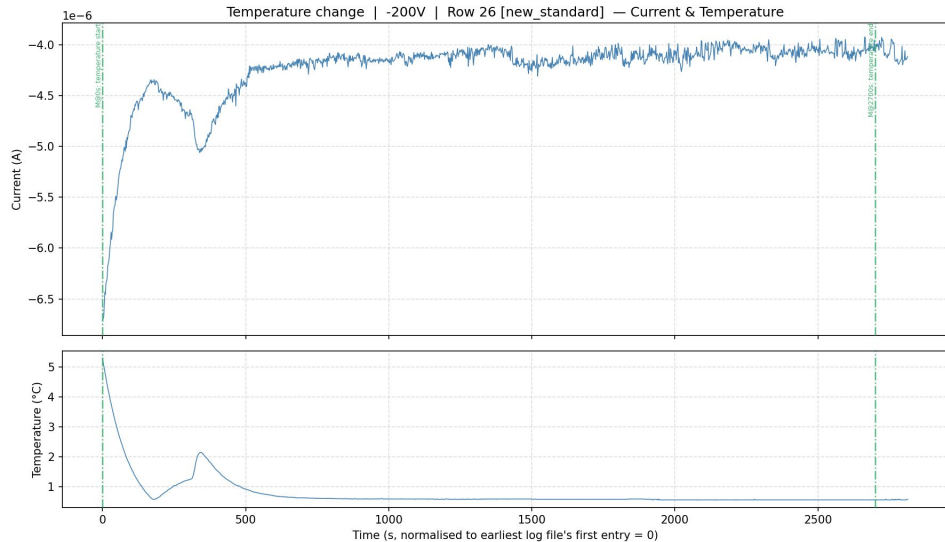
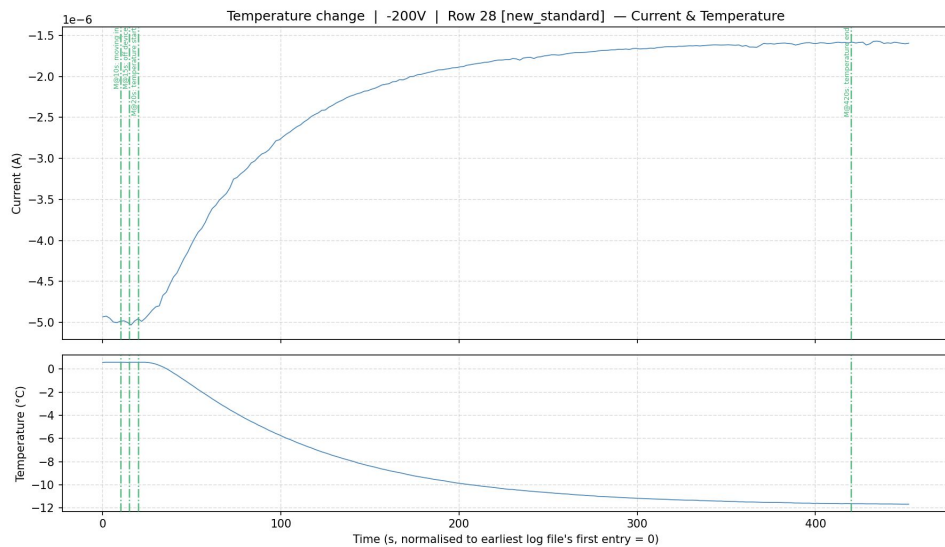
- InP: $1.30\text{E-}16$ A/cm | Silicon: $3.99\text{E-}17$ A/cm
- Why this InP alpha derivation is a lower bound estimate
 - Electric field simulations from here in Thin Films showed our device geometry shows **electric field lines** curve inward
 - **Frustrum** is overestimation of volume \rightarrow alpha parameter is underestimation
- Follow-Up:
 - For an accurate measurement, we may need temperature controlled measurements using the parameter analyzer (multi-channel for GR separation)

Electric Field Simulation Pictures
Here, if slides are on Indico (couldn't find them)



Long Scans - Temperature - 1

- Record dark current as a function of temperature
- Get Arrhenius plot and derive activation energy
 - Bandgap or deep Fe traps?



Long Scans - Temperature - 2

5. Arrhenius (temperature plot, `temperature_arrhenius_fit_parameters.csv`)

$$|I(T)| = A \cdot \exp\left(-\frac{E_a}{k_B T_K}\right) \quad \text{with } T_K = T_C + 273.15$$

Fit performed by linear regression on $\ln |I|$ vs $1/T_K$:

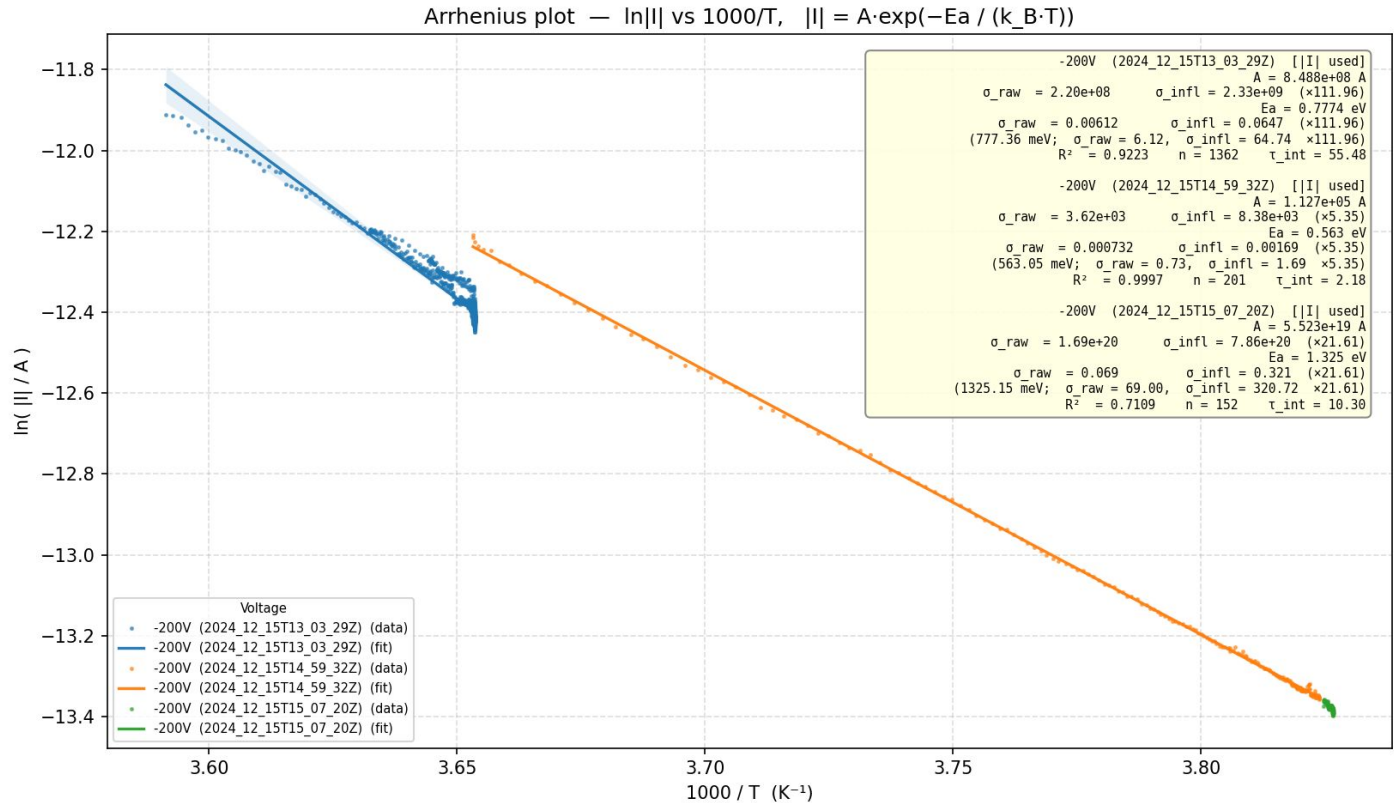
$$\ln |I| = \ln A - \frac{E_a}{k_B} \cdot \frac{1}{T_K}$$

so slope = $-E_a/k_B$, intercept = $\ln A$. E_a reported in eV using $k_B = 8.617333262 \times 10^{-5}$ eV/K.

Long Scans - Temperature - 3

Remap measured current + temp as functions of time into current vs temp, then fit to Arrhenius

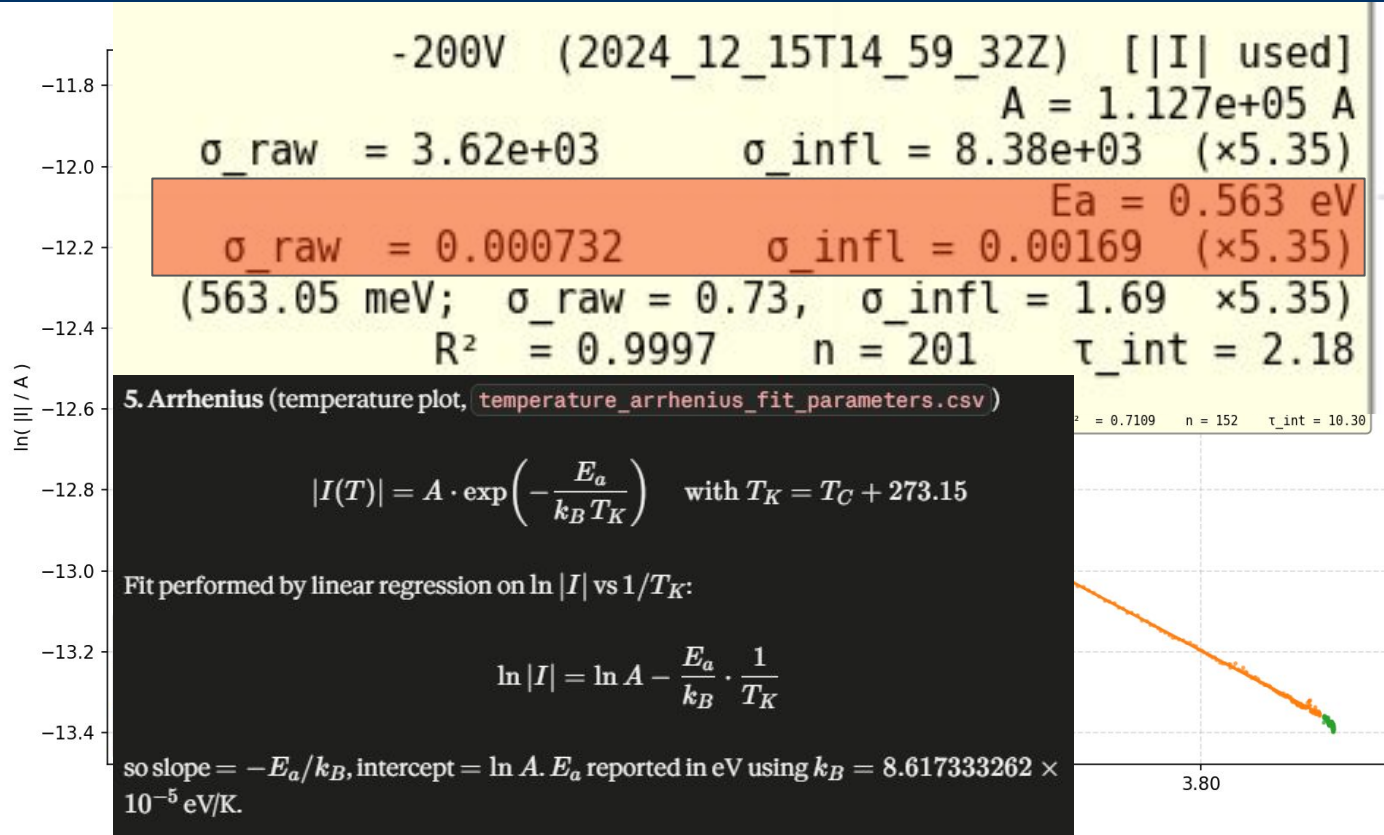
Assume dark current from thermally-driven carrier exchange between energy levels



Long Scans - Temperature - 4

Activation energy
 ~trap-to-band gap
 → Dark current is driven by carrier exchange with the Fe traps, not bandgap

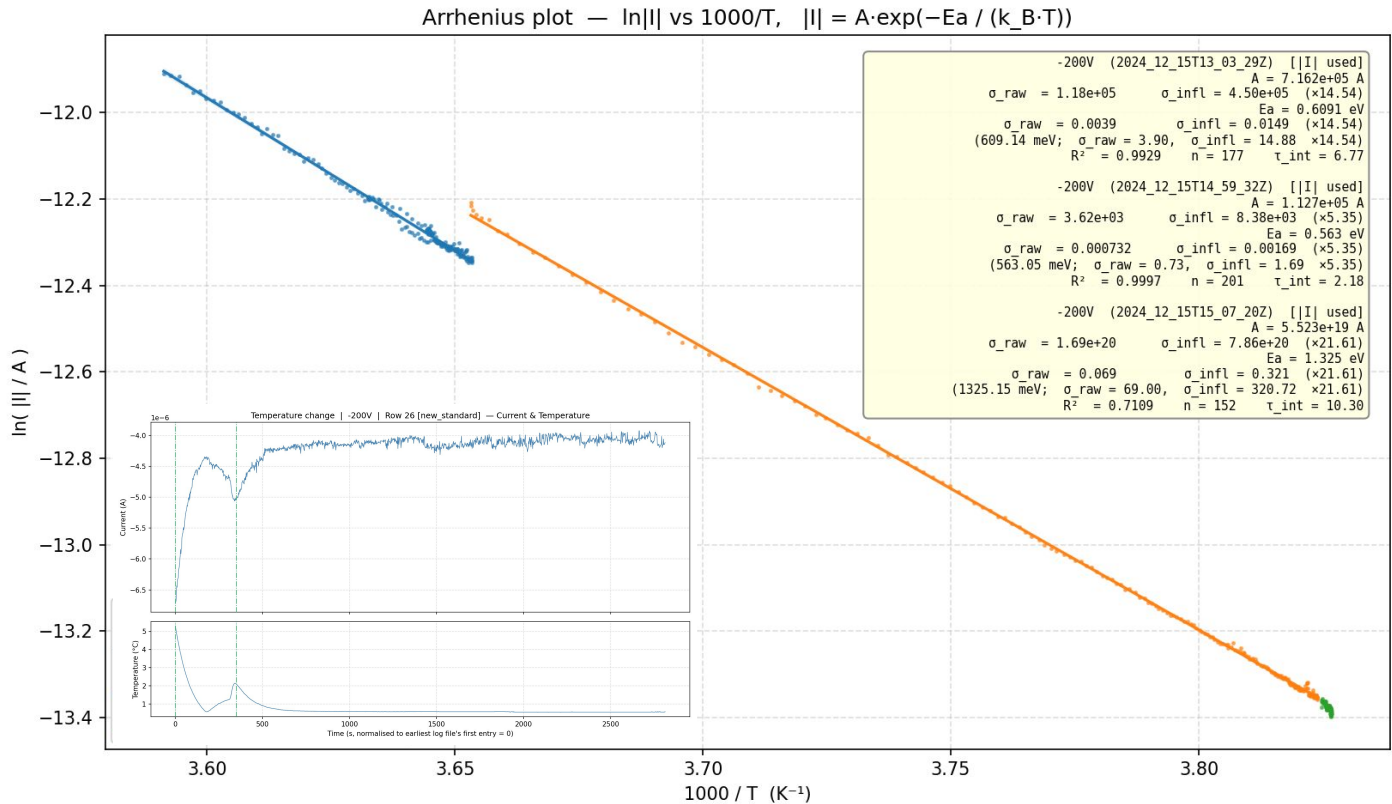
Low uncertainty from scipy fit



Long Scans - Temperature - 5

Removing tail end of blue data / large cluster at high current leads to better matching E_a between runs.

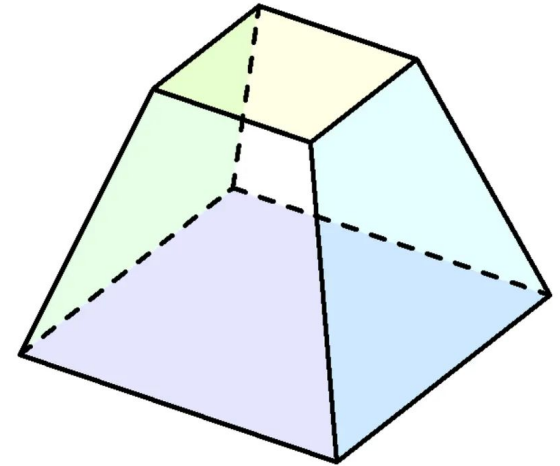
Later tail likely contains other processes not related to thermal exchange of carriers



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